5P

	Application No.	Applicant(s)	
Notice of Allowability	10/730,559	FEHER ET AL.	
	Examiner	Art Unit	
	Quang T Van	3742	
The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED i or other appropriate comm GHTS. This application is	in this application. If not including the in	ded course. THIS
1. X This communication is responsive to AMendment filed on a	12/01/2004.		
2. The allowed claim(s) is/are <u>1-4</u> .	•		
3. The drawings filed on are accepted by the Examine	r.		
 4. Acknowledgment is made of a claim for foreign priority ur a) All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 3. Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN 	been received. been received in Applicati cuments have been receive	ion No ed in this national stage applic	
 THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. A SUBSTITUTE OATH OR DECLARATION must be subminformal PATENT APPLICATION (PTO-152) which give 	itted. Note the attached EX es reason(s) why the oath o	(AMINER'S AMENDMENT or or declaration is deficient.	NOTICE OF
 CORRECTED DRAWINGS (as "replacement sheets") must (a) ☐ including changes required by the Notice of Draftspers 1) ☐ hereto or 2) ☐ to Paper No./Mail Date (b) ☒ including changes required by the attached Examiner' Paper No./Mail Date 03/03/2005. Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in the state of the sheet of th	son's Patent Drawing Revie . s Amendment / Comment c .84(c)) should be written on he header according to 37 C	or in the Office action of the drawings in the front (not the	
7. DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT	sit of BIOLOGICAL MAT FOR THE DEPOSIT OF BI	FERIAL must be submitted. IOLOGICAL MATERIAL.	Note the
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/O Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit of Biological Material	6. Interview S Paper No 98), 7. Examiner's	nformal Patent Application (PTSummary (PTO-413), p./Mail Date s Amendment/Comment s Statement of Reasons for Alwings. Quang T Van Primary Examiner Art Unit: 3742	lowance

Application/Control Number: 10/730,559 Page 2

Art Unit: 3742

Drawings

1. The drawings filed 12/01/2004 are considered as informal because all the lines and reference numerals are rough and non-uniform. The descriptive words in the Figures are also not legible. Since the application having been allowed, formal drawings are required in response to this Office Action.

REASON FOR ALLOWANCE

2. The following is an examiner's statement of reasons for allowance: allowance of claims 1-4 is indicated because the prior art of record does not show or suggest a dielectric tube extending through said applicator parallel to the axis of said microwave in-coupling opening in said applicator and normal to opposite side walls of said applicator, of which one includes said in-coupling opening, a metallic tube stub sealingly connected to each of opposite ends of said dielectric tube outside said applicator for conducting a fluid to be heated through said applicator, which fluid forms a load, said tube stubs being also joined to said opposite side walls of the applicator in a microwavetight manner, wherein said applicator has rectangular shape which is adapted to the wavelength A of the microwave supplied by the microwave source in such a way that, in the applicator, the linearly polarized base mode TE₁₀ of the microwave is excited, the axis of said dielectric tube extends parallel to the field polarization of the linearly polarized TE₁₀ mode and is disposed at a distance of about λ/4 from the respective nearest front wall of said applicator, and the axis of the dielectric tube coincides with the field maximum of the linearly polarized TE₁₀ mode, the distance between the center point of the incoupling opening and the axis of the dielectric tube is so selected that field Application/Control Number: 10/730,559

Art Unit: 3742

energy coupled into the applicator is completely or nearly completely absorbed in the dielectric tube through which the fluid to be heated is conducted and converted therein to heat, such that no or only negligible reflections occur in the applicator, and said tub stubs have an open width adjacent the side walls of the applicator, which equals the outer diameter of the dielectric tube over a length of $\lambda/4$ to $\lambda/2$, and their diameter becomes then smaller over a length of > $\lambda/4$ so as to provide a blocking structure preventing an escape of any microwaves from said applicator as recited in claims 1-4.

Page 3

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

3. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Quang T Van whose telephone number is 571-272-4789. The examiner can normally be reached on 8:00Am 7:00Pm M-Th.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Robin Evans can be reached on 571-272-4777. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Application/Control Number: 10/730,559

Art Unit: 3742

Page 4

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic

Business Center (EBC) at 866-217-9197 (toll-free).

QV

March 3, 2005

Quang T Van Primary Examiner

Art Unit 3742